

Electronic Acknowledgement Receipt

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International Application Number:	
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Title of Invention:	Positive-type resist composition for liquid immersion lithography and method for forming resist pattern
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Document Number	Document Description	File Name	File Size(Bytes)/ Message Digest	Multi Part /.zip	Pages (if appl.)
1	Information Disclosure Statement (IDS) Filed (5B/08)	1608-7_PCT-US_IDS_3-19-09.pdf	871143	no	4
			18740428c6b2a48c7a5f8c56a64bcb014305da		
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2	Foreign Reference	EP1319981.pdf	3193477 e99c73ba1b6cc5e4e4171a1a13a55896d5d0c78	no	80
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3	Foreign Reference	EP1505439.pdf	2060009 30fba33892244a7a81c06f190bc1cd97c0a89421	no	63
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4	NPL Documents	Sato_article.pdf	1089917 67d8e4d670acc182610d70870f8cad1fa71578	no	20
Warnings:					
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5	NPL Documents	Taylor_article.pdf	480409 d0b7e2be51378e6b6c3ae622932ce0bae54b29e	no	10
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6	NPL Documents	Hinsberg_article.pdf	871361 20411c785c48f9a6946d2c9c36c0c0e5f52c80e	no	13
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7	NPL Documents	Supplementary_SR.pdf	186567 d2aa121056b7a5c55442c813d8c7b1ab0704ac	no	5
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National Stage of an International Application under 35 U.S.C. 371

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